An exponentially weighted moving average scheme with variable sampling intervals for monitoring linear profiles

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Abstract

This paper proposes an exponentially weighted moving average scheme with variable sampling intervals for monitoring linear profiles. A computer program in Fortran is available to assist in the design of the control chart and the algorithm of the Fortran program is also given. Some useful guidelines are also provided to aid users in choosing parameters for a particular application. Simulation results on the detection performance of the proposed control chart, compared with some other competing methods show that it provides quite robust and satisfactory performance in various cases, including intercept shifts, slope shifts and standard deviation shifts. A real data example from an optical imaging system is employed to illustrate the implementation and the use of the proposed control scheme.

Key words: Linear Profile; Control Chart Design; Computer Simulation; Statistical Process Control; Reliability Engineering.

1 Introduction

Statistical process control (SPC) has been widely used to monitor various industrial processes in reliability engineering. Most of research on SPC focused on the charting techniques and it was assumed that the quality of a process or product can be adequately represented by the univariate distribution of a quality characteristic or by the multivariate distribution of a vector consisting of several quality characteristics. However, in many practical situations,

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the quality of a process or product is better characterized by a relationship between a response variable and one or more explanatory variables. So there has been recent interest in monitoring process or product characterized by a simple linear profile. For Phase I control charts, Mahmoud and Woodall (2004) propose a method based on using indicator variables in a multiple regression model and Mahmoud et al. (2007) propose a change point approach based on the segmented regression technique for testing the constancy of the regression parameters. For Phase II control charts, Kang and Albin (2000) propose two monitoring approaches: one is multivariate T^2 and the other one is a combination of exponentially weighted moving average (EWMA) and R chart. Based on the transformed model, Kim et al. (2003) recommend use of three univariate EWMA control charts ($EWMA_3$) for detecting shifts in the intercept, slope and the standard deviation simultaneously. Simulation results of Kim et al. (2003) and Gupta et al. (2006) show that $EWMA_3$ has better performance in terms of average run length (ARL), which is defined as the average number of samples before the chart signals an out-of-control condition. Recently, Zhang et al. (2009) propose a control chart based on EWMA and Likelihood Ratio test (ELR) for monitoring linear profiles. Besides simple linear profile, Zou et al. (2007) propose a Multivariate EWMA (MEWMA) scheme when the quality of a process can be characterized by a general linear profile. Woodall et al. (2004) discuss some of the general issues about the problems of linear profiles and encourage research in profile monitoring. In a recent review paper, Woodall (2007) shows that the profile monitoring framework includes applications such as lumber manufacturing, monitoring of shapes, organic pigments applied to cotton surfaces, shelf-life of a food product, public health surveillance, and etc.

Extensive research in recent years has developed Variable Sample Rate (VSR) control charts that vary the sampling rate as a function of current and prior sample results. The advantage of using a VSR chart instead of a Fixed Sampling Rate (FSR) chart is that a VSR chart provides much faster detection of small and moderate process changes, for a given in-control ARL and a given in-control average sampling rate. There are several approaches that can be used to vary the sampling rate. One approach is a Variable Sampling Intervals (VSI) chart that varies the sampling intervals as a function of the sample results from the process. Another approach to varying the sample rate is a Variable Sample Size (VSS) chart that varies the sample sizes as a function of the sample results from the process. The VSI and VSS features can be combined to give a Variable Sample Sizes and Sampling Intervals (VSSI) control chart that allows the sample sizes and sampling intervals to vary. There have been lots of research on conventional control chart using VSR features in the literature, for the $\overline{X}$ control chart, see Prabhu et al. (1994), Costa (1998), Chen and Chiou (2005) and Celano et al. (2006); for the cumulative sum (CUSUM) control chart, see Reynolds et al. (1990), Zhang and Wu (2007) and Wu et al. (2007); for the EWMA control chart, see Reynolds (1996) and

Reynolds and Arnold (2001); for the cumulative count of conforming chart, see Liu et al. (2006) and for the Hotelling's T^2 control chart, see Aparisi and Haro (2001). For the $\overline{X}$ control chart, Chen and Liao (2004) study multi-criteria design and show that the design parameters of sample sizes and sampling intervals need to be adjusted. Shamsuzzaman et al. (2009) propose an algorithm for deploying manpower to an $\overline{X}$ & S control chart which minimizes the expected total cost.

Montgomery (2007) shows that one important area of SPC research continues to be the use of control charts with variable sample sizes and/or sampling intervals. Although there have been lots of research on conventional control charts using VSR features in the literature, there is little work on linear profile monitoring schemes, except the VSI MEWMA of Zou et al. (2007) and the VSI ELR of Zhang et al. (2009), against which we compare our proposed chart. As Woodall (2007) points out, profile monitoring is very useful in an increasing number of practical applications, the objective of this paper is to perform a detailed investigation of an EWMA scheme with variable sampling intervals (VSI $EWMA_3$) for monitoring linear profiles in which it is desirable to determine the sampling interval for the next sample before sampling is started for this sample. As Zou et al. (2007) point out, the design of a combination of VSI $EWMA_3$ is not at all trivial, because three warning limits and three control limits must be chosen simultaneously so that all charts have the same individual in-control average sampling rate and average false alarm rate. We overcome this difficulty by transforming the three EWMA statistics to one omnibus statistic.

The rest of this paper is organized as follows. In the next section, some competitive schemes are briefly introduced. Our proposed VSI $EWMA_3$ and its designing strategies are presented in Section 3. The numerical comparisons with the $EWMA_3$ of Kim et al. (2003), the VSI MEWMA of Zou et al. (2007) and the VSI ELR of Zhang et al. (2009) are carried out in Section 4. A real data example from an optical imaging system is used to illustrate the VSI $EWMA_3$ in Section 5. Some computation aspects are presented in Section 6. Several remarks conclude this paper in Section 7.

2 EWMA control charts for monitoring linear profiles

In this section, the $EWMA_3$ of Kim et al. (2003), the MEWMA of Zou et al. (2007) and the ELR of Zhang et al. (2009) are briefly introduced.

The $EWMA_3$ chart

Assume that the jth random sample collected over time is $(x_i, y_{ij}), i = 1, 2, \ldots, n_i$.

When the process is in control, the relationship between the response variable and the explanatory variables is assumed to be

$$y_{ij} = A_0 + A_1 x_i + \epsilon_{ij}, i = 1, 2, \ldots, n_i,$$

where ϵ_{ij}/σ is an independent identically distributed (i.i.d) as standard normal random variable. We assume that n_i are all equal to n. This is usually the case in many practical applications. When the parameters A_0, A_1 and σ^2 are unknown, they can be estimated from Phase I sample data. Suppose that there are, in total, $m(m \geq 1)$ in-control samples of size n, $\{(x_i, y_{ij}), i = 1, 2, \ldots, n; j = 1, 2, \ldots, m\}$. The most often used unbiased estimators of A_0, A_1 and σ^2 are the average of the m least square estimators, a_{0j}, a_{1j} and MSE_j, which are given by

$$a_{0j} = \overline{y_j} - a_{1j}\overline{x},$$
$$a_{1j} = \frac{S_{xy(j)}}{S_{xx}},$$
$$MSE_j = \frac{1}{n-2} \sum_{i=1}^{n} (y_{ij} - a_{1j}x_i - a_{0j})^2,$$

where

$$\overline{y_j} = \frac{1}{n} \sum_{i=1}^{n} y_{ij}, \overline{x} = \frac{1}{n} \sum_{i=1}^{n} x_i, S_{xx} = \sum_{i=1}^{n} (x_i - \overline{x})^2, S_{xy(j)} = \sum_{i=1}^{n} (x_i - \overline{x}) y_{ij}.$$

After the estimations are determined, the parameters are assumed to be known and the Phase II monitoring could be started. In the following of this paper, we focus on Phase II monitoring linear profiles.

Kim et al. (2003) code the explanatory values and obtain the following alternative form of the relationship model:

$$y_{ij} = B_0 + B_1 x_i^* + \epsilon_{ij}, i = 1, 2, \ldots, n, \tag{1}$$

where

$$B_0 = A_0 + A_1\overline{x}, B_1 = A_1, x_i^* = x_i - \overline{x}.$$

For the jth sample, the least square estimators of $B_0, B_1,$ and σ^2 are

$$b_{0j} = \overline{y_j},$$
$$b_{1j} = \frac{S_{xy(j)}}{S_{xx}},$$
$$MSE_j = \frac{1}{n-2} \sum_{i=1}^{n} (y_{ij} - b_{1j}x_i^* - b_{0j})^2.$$

Note that these three estimators are independent. Kim et al. (2003) propose using three EWMA charts ($EWMA_I, EWMA_S, EWMA_E$) to monitor the changes of Y-intercept (B_0), the slope (B_1) and the standard deviation (σ), respectively. They are

$$
\begin{aligned}
E_I(j) &\triangleq EWMA_I(j) = \theta b_{0j} + (1-\theta)EWMA_I(j-1), \\
E_S(j) &\triangleq EWMA_S(j) = \theta b_{1j} + (1-\theta)EWMA_S(j-1), \\
E_E(j) &\triangleq EWMA_E(j) = \max\{\theta \ln(MSE_j) \\
&\qquad\qquad\qquad + (1-\theta)EWMA_E(j-1), \ln(\sigma^2)\},
\end{aligned} \tag{2}
$$

where $0 < \theta \leq 1$ is a smoothing parameter, $E_I(0) = B_0, E_S(0) = B_1$, and $E_E(0) = \ln(\sigma^2)$. The smoothing parameter θ is set at 0.2, which is a typical choice in the literature (Kang and Albin (2000), Kim et al. (2003), Zou et al. (2007) and Zhang et al. (2009)). The three EWMA charts are used jointly.

The $EWMA_3$ gives a signal as soon as one or more of the following three conditions hold.

$$
\begin{aligned}
|E_I(j) - B_0| &> L_I \sigma \sqrt{\frac{\theta}{(2-\theta)n}}, \\
|E_S(j) - B_1| &> L_S \sigma \sqrt{\frac{\theta}{(2-\theta)S_{xx}}}, \\
E_E(j) &> L_E \sqrt{\frac{\theta}{2-\theta}\mathtt{Var}[\ln(MSE_j)]},
\end{aligned} \tag{3}
$$

where L_I, L_S and L_E are chosen to give a specified in-control ARL and

$$
\mathtt{Var}[\ln(MSE_j)] \approx \frac{2}{n-2} + \frac{2}{(n-2)^2} + \frac{4}{3(n-2)^3} - \frac{16}{15(n-2)^5}.
$$

As Liu et al. (2006) indicate, in practical applications, people are more concerned at the process deterioration rather than improvement, so we focus on the statistic E_E, designed to detect an increase in variance.

The MEWMA chart

Assume that the jth random sample is $(\mathbf{X}_j, \mathbf{Y}_j)$, where $\mathbf{Y}_j$ is n_j-variate vector and $\mathbf{X_j}$ is a $n_j \times p$ ($n_j > p$) matrix. When the process is in-control, the underlying model is

$$
\mathbf{Y}_j = \mathbf{X}_j \vec{\beta} + \vec{\varepsilon}_j,
$$

where $\vec{\beta} = (\beta^{(1)}, \beta^{(2)} \cdots, \beta^{(p)})$ is the p-dimensional coefficient vector and the $\vec{\varepsilon}'_j$s are i.i.d as an n_j-variate multivariate normal random vector with mean $\vec{0}$ and $\sigma^2 \mathbf{I}$ covariance matrix. The n'_js are assumed to be equal and $\mathbf{X}_j$ is assumed to be fixed for different j, denoted as n and $\mathbf{X}$, respectively. Define

$$\mathbf{Z}_j(\vec{\beta}) = (\widehat{\vec{\beta}}_j - \vec{\beta})/\sigma, \quad Z_j(\sigma) = \Phi^{-1}\{F((n-p)\widehat{\sigma}_j^2; n-p)\}$$

where $\widehat{\vec{\beta}}_j = (\mathbf{X}'\mathbf{X})^{-1}\mathbf{X}'\mathbf{Y}_j$, $\widehat{\sigma}_j^2 = \frac{1}{n-p}(\mathbf{Y}_j - \mathbf{X}\widehat{\vec{\beta}}_j)'(\mathbf{Y}_j - \mathbf{X}\widehat{\vec{\beta}}_j)$, Φ^{-1} is the inverse of the standard normal cumulative distribution function, and $F(\cdot; \nu)$ is the chi-squared distribution function with ν degrees of freedom.

Zou et al. (2007) defines the EWMA charting statistic as

$$\mathbf{W}_j = \theta \mathbf{Z}_j + (1 - \theta)\mathbf{W}_{j-1}, j = 1, 2, \cdots,$$

where $\mathbf{Z}_j = (\mathbf{Z}'_j(\widehat{\vec{\beta}}), Z_j(\sigma)')$. The MEWMA signals when

$$U_j = \mathbf{W}'_j \mathbf{\Sigma}^{-1} \mathbf{W}_j > L\frac{\theta}{2 - \theta},$$

where $L > 0$ is chosen to achieve a specified in-control ARL and $\mathbf{\Sigma} = \begin{pmatrix} (\mathbf{X}'\mathbf{X})^{-1} & \mathbf{0} \\ \mathbf{0} & 1 \end{pmatrix}$ is the in-control covariance matrix of $\mathbf{Z}_j$.

The ELR chart

Zhang et al. (2009) obtain the generalized likelihood ratio statistic for sample j as follows

$$LR_j = \mathrm{C}_j - n \log \widehat{\sigma}_j^2 - n,$$

where

$$\mathrm{C}_j = \sum_{i=1}^{n}(y_{ij} - B_0 - B_1 x_i^*)^2, \quad \widehat{\sigma}_j^2 = \frac{1}{n}\sum_{i=1}^{n}(y_{ij} - b_{1j}x_i^* - b_{0j})^2.$$

Subsequently, four EWMA statistics are introduced by

$$\mathrm{EI}_j = \theta b_{0j} + (1 - \theta)\mathrm{EI}_{j-1}, \quad \mathrm{ES}_j = \theta b_{1j} + (1 - \theta)\mathrm{ES}_{j-1},$$

$$\mathrm{EE}_j = \theta S_j^* + (1 - \theta)\mathrm{EE}_{j-1}, \quad \mathrm{EC}_j = \theta \mathrm{C}_j + (1 - \theta)\mathrm{EC}_{j-1},$$

where $\mathrm{EI}_0 = B_0$, $\mathrm{EE}_0 = 1$, $\mathrm{EC}_0 = n$, $S_j^* = \frac{1}{n}\sum_{i=1}^{n}(y_{ij} - \mathrm{ES}_j x_i^* - \mathrm{EI}_j)^2$ and $\mathrm{ES}_0 = B_1$.

6

Finally, they substitute EC_j and EE_j for C_j and $\widehat{\sigma}_j^2$ in LR_j and obtain the charting statistics

$$ELR_j = EC_j - n \log EE_j - n. \tag{4}$$

If $ELR_j > L$, an alarm is triggered.

3   The VSI $EWMA_3$ control chart

The VSI $EWMA_3$ is the $EWMA_3$ control chart, defined in Equation (2) and (3), using a longer sample interval as long as the sample point is close to the target so that there is no indication of process changes. However, if the sample point is far from the target, but still within the action limits, a shorter sampling interval is used. If a sample point falls in the action region, then the process is considered to be out of control.

Assume that in the conventional linear profile monitoring, the fixed sampling interval is d_0. In general, for our VSI $EWMA_3$, the sampling interval function $d(\cdot)$ can be of any form, but previous research on VSI control charts has shown that it is sufficient to use only two possible values for the sampling intervals to achieve good statistical properties in VSI control charts, see, for example, Costa (1998), Wu et al. (2007) and Reynolds and Arnold (2001). Let d_1 and d_2 represent these two possible sampling intervals, where $0 < d_1 < d_2$. Then the sampling interval function $d(\cdot)$ can be defined by partitioning C, the continuation or in-control region, into two regions, say warning region R_w and central region R_c, such that

$$d(\cdot) = \begin{cases} d_1, \text{ if the monitor statistic falls into } R_w, \\ d_2, \text{ if the monitor statistic falls into } R_c. \end{cases}$$

It is advisable to start the control with the shorter sampling interval, d_1, so the first sample is taken quickly after the process is started in case of start-up problems.

Unlike VSI control charts for $\overline{X}$ control charts, CUSUM control charts, or EWMA control charts, it is quite difficult to specify the regions R_w and R_c for the VSI $EWMA_3$. The reason is that the monitoring statistics $E_I(j)$, $E_S(j)$ and $E_E(j)$ do not have an explicit in-control distribution, although b_{0j} and b_{1j} are known to be normally distributed with means B_0 and B_1 and variances σ^2/n and σ^2/S_{xx}, respectively.

To overcome these problems, we divide the three monitor statistics $E_I(j)$,

$E_S(j)$ and $E_E(j)$ by the three corresponding control limits. That is, what we plot are

$$SE_I(j) \triangleq \frac{|E_I(j) - B_0|}{L_I \sigma \sqrt{\frac{\theta}{(2-\theta)n}}},$$

$$SE_S(j) \triangleq \frac{|E_S(j) - B_1|}{L_S \sigma \sqrt{\frac{\theta}{(2-\theta)S_{xx}}}},$$

$$SE_E(j) \triangleq \frac{E_E(j)}{L_E \sqrt{\frac{\theta}{2-\theta} Var[\ln(MSE_j)]}}. \tag{5}$$

In this condition, the VSI $EWMA_3$ control chart signals as soon as $\Delta(j) > 1$, where

$$\Delta(j) = \max \{SE_I(j), SE_S(j), SE_E(j)\}. \tag{6}$$

Then our VSI $EWMA_3$ can use warning limit ω and control limit $h \equiv 1$ to divide the chart into the central region $R_c = (0, \omega)$, warning region $R_w = [\omega, 1)$ and action region $[1, +\infty)$.

To facilitate the derivation of ω, define p_0 as the conditional probability of a sample point $\Delta(j)$ falling in the central region given that this point does not fall in the action region, i.e.,

$$p_0 = P[\Delta(j) < \omega | \Delta(j) < 1].$$

A large value of p_0 indicates that the value ω is close to 1, and a large number of samples is taken using the longer sampling interval d_2. Due to the intricacy of the distribution of $\Delta(j)$, we can only find the warning limit ω corresponding to different p_0 through Monte Carlo simulation. As Kim et al. (2003), it is assumed in this paper that the underlying in-control linear profile model is $y_{ij} = 13 + 2x_i^* + \epsilon_{ij}$, where the ϵ_{ij}'s are i.i.d as standard normal random variables. The x_i^* values are -3(2)3 with $\overline{x^*} = 0$. As expected, ω is related to the sample size n, the explanatory variables $x_1, \ldots, x_n$ and the control limits L_I, L_S, L_E. Given these, a Fortran program to find corresponding ω is available from the authors upon request. The corresponding algorithm is deferred in Section 6 to avail practitioners.

Although it is needed to change the original three monitoring statistics E_I, E_S and E_E into one statistic $\Delta(j)$, it does not hamper the diagnostic ability of the VSI $EWMA_3$ at all. Once $\Delta(j)$ gives an out-of-control signal for some j, all needs to be done is check which one of the three monitoring statistics

E_I, E_S and E_E is the maximum. If this maximum is E_I, E_S or E_E, there is significant cause to generate a process change in the intercept, the slope or the standard deviation. We do not need separate parametric tests as in Zou et al. (2007), which is appealing for the practitioners because they may be reluctant to take extra effort to diagnose which parameter has changed.

3.1   The sensitivity analysis of VSI $EWMA_3$ chart

Traditionally, the ARL has been generally employed as a performance indicator to evaluate the effectiveness of various control schemes, provided that the sampling interval remains constant. However, when the sampling interval is variable, the time to signal is not a constant multiple of the ARL, and thus ARL is not appropriate for evaluating the effectiveness of VSI control charts. The widely used performance indicators for control charts with VSI are the average time to signal (ATS), which is defined as the expected value of time from the start of the process to the time when the charts indicate an out-of-control signal, and the adjusted average time to signal (AATS), which is defined as the expected value of time from the occurrence of an assignable cause to the time when the charts indicate an out-of-control signal. The AATS is also called the steady-state ATS (SSATS).

When the process is in control, the ATS may be used to develop the measures of the false alarm rate for a chart. A chart with a larger in-control ATS indicates a lower false alarm rate than other charts. When the process is out of control, the AATS may be used to measure the performance of a chart. A chart with a smaller out-of-control AATS indicates a better detection ability of process shifts than other charts. To make the linear profile monitoring schemes with and without VSI comparable, the same in-control average sample rate is used, i.e.,

$$(1 - p_0)d_1 + p_0 d_2 = d_0. \tag{7}$$

The performance of the VSI $EWMA_3$ is related to determination of the following parameters: the warning limit ω, the sampling interval d_1 and d_2. Of course, the parameters L_I, L_S and L_E involved in computing the statistics $\Delta(j)$ should be specified first to give a specified in-control ATS. They can be determined by simulation according to Kim et al. (2003).

In this paper, it is assumed that $d_0 = 1$ without loss of generality. Otherwise, the results can be obtained multiplied by d_0. Kim et al. (2003) show that $L_I = 3.0156, L_S = 3.0109$ and $L_E = 1.3723$ give an overall in-control ARL of roughly 200. Thus the ATS is 200 under the assumption that $d_0 = 1$.

To facilitate the determination of ω, the conditional probability p_0, which can be considered as the proportion of samples taken using the longer sampling interval d_2 when the process is in control, needs to be specified. Figure 1 (a)-(c) provide the ATS and AATS for several VSI linear profile monitoring schemes with various p_0 when the intercept B_0, the slope B_1 and the standard deviation σ changes to $B_0 + \lambda\sigma, B_1 + \delta\sigma$ and $\gamma\sigma$, respectively. These are on a log scale for a clearer comparison. In Figure 1, $d_1 = 0.1$ and d_2 computed from Equation (7) are used. Figure 1 shows that the VSI $EWMA_3$ with smaller p_0 value has a smaller out-of-control AATS when the in-control ATS is approximately 200, which results in a quicker detection of process shifts. It seems that p_0 should be as small as possible from statistical point of view. However, too small a p_0 gives too large a d_2 for fixed d_1, which implies that once $\Delta(j)$ falls in R_c, too long a sampling interval will be used. This is not realistic in practice. For EWMA and $\overline{X}$ control chart, Reynolds (1996) and Lin and Chou (2005a) suggest that the p_0 value should be in the vicinity of 0.8. Therefore, we suggest to use a p_0 value in the vicinity of 0.8 for the VSI $EWMA_3$.

Insert Figure 1 about here.

When the VSI $EWMA_3$ is used, the sampling intervals may vary. The detection ability depends on the sampling intervals d_1 and d_2. Figure 2 (a)-(c) provide the ATS and AATS (on a log scale) for several VSI $EWMA_3$ with various d_1 and d_2 computed from Equation (7) when the intercept B_0, the slope B_1 and the standard deviation σ changes to $B_0 + \lambda\sigma, B_1 + \delta\sigma$ and $\gamma\sigma$, respectively. In Figure 2, $p_0 = 0.8$ is used based on the discussions above. Figure 2 shows that the VSI $EWMA_3$ with smaller d_1 value has a smaller out-of-control AATS. It seems that d_1 should be as small as possible. However, d_1 depends on the shortest time required to sample each item in practice. Thus, d_1 may be equal to the shortest time to sample each item.

Insert Figure 2 about here.

3.2   The design procedure of VSI $EWMA_3$ chart

For designing the VSI $EWMA_3$ chart, we should find a combination of parameters $(p_0, \omega, d_1, d_2, L_I, L_S, L_E)$ that achieves the specified in-control ATS and the chart signals quickly when the process undergoes a shift. From the performance of the VSI $EWMA_3$ chart shown in Figures 1-2, the following design procedure is recommended.

(1) Set the in-control ATS according to the administrative consideration and determine the values of L_I, L_S and L_E, which can be obtained through simulation. They are selected under the criterion that the statistics E_I, E_S and E_E are equally important, i.e., the control charts with E_I, E_S and

E_E give nearly the same in-control ATS individually. See more details in Kim et al. (2003). If a manager, however, does not think the statistics E_I, E_S and E_E are equally important, we can control individual in-control average false-alarm rate by adjusting L_I, L_S and L_E.

(2) Choose the conditional probability p_0. It may be in the vicinity of 0.8 if there is no special requirement.

(3) Choose the warning limit ω by a computer program, which guidelines are detailed in Section 6. A Fortran program is also available from the authors upon request.

(4) Determine the shorter sampling interval d_1. It may be the shortest time to sample each item. In the literature, $d_1 = 0.01, 0.1$ for $\overline{X}$ control chart in Prabhu et al. (1994), $d_1 = 0.1, 0.5$ for CUSUM charts in Reynolds et al. (1990), $d_1 = 0.1, 0.25$ for EWMA control charts in Reynolds and Arnold (2001), $d_1 = 0.1, 0.2$ for Hotelling's T^2 control chart in Aparisi and Haro (2001) and $d_1 = 0.1, 0.25, 0.5$ for MEWMA control chart in Zou et al. (2007). So $d_1 = 0.1$ is a typical choice if it is feasible to sample again after the current sample is obtained.

(5) d_2 is computed from Equation (7).

4   Comparisons

In this section, a comparative study is conducted by Monte Carlo simulation to evaluate the performance of the VSI $EWMA_3$. The simulations are sufficiently long, 10,000 replications, such that the standard errors of the estimates are less than 2%, enabling us to draw reasonable conclusions. The in-control ATS of each chart is set to be equal, and so is the in-control average sample rate, such that the comparisons can be conducted under the same criteria.

4.1   Comparison with $EWMA_3$

To compare with the result of Kim et al. (2003), note that the standard deviation σ is 1 and the in-control ATS is approximately 200 under the assumption that $d_0 = 1$. From the design strategies in the previous section, $p_0 = 0.8$ and $d_1 = 0.1, 0.25, 0.5$ are employed for the VSI $EWMA_3$. After p_0 and d_1 are determined, d_2 is computed from Equation (7). From our computer program, the warning limit ω corresponding to $p_0 = 0.8$ is 0.56.

The AATS comparisons under intercept shifts from B_0 to $B_0 + \lambda\sigma$, under slope shifts from B_1 to $B_1 + \delta\sigma$, under combinations of intercept and slope shifts, and under deviation shifts from σ to $\gamma\sigma$ are shown in Tables 1–2, respectively. These shift patterns cover a wide range of shifts in practice. In these tables,

11

Table 1
AATS comparisons with $EWMA_3$ under intercept and slope shifts

	$B_1 + \delta\sigma$						δ					
	$B_0 + \lambda\sigma$	0.000	0.025	0.050	0.075	0.100	0.125	0.150	0.175	0.200	0.225	0.250
0.00	$EWMA_3$	197.8	174.2	121.5	76.6	48.3	32.8	23.2	17.0	13.2	10.7	8.8
	$VSIEWMA_3(d_1 = 0.1)$	197.5	171.0	114.7	67.7	39.3	24.6	16.1	10.9	7.9	6.1	4.8
	$VSIEWMA_3(d_1 = 0.25)$	197.0	167.5	111.9	69.4	41.6	25.6	17.1	11.8	8.8	6.8	5.6
	$VSIEWMA_3(d_1 = 0.5)$	197.6	169.6	116.3	71.0	44.3	28.1	18.7	13.6	10.2	8.1	6.7
0.05	$EWMA_3$	176.5	157.6	114.7	74.8	48.3	32.2	22.5	16.9	13.2	10.7	8.9
	$VSIEWMA_3(d_1 = 0.1)$	173.8	150.4	105.1	65.2	38.1	24.1	15.5	10.8	7.9	6.0	4.8
	$VSIEWMA_3(d_1 = 0.25)$	173.6	154.3	105.8	66.2	39.7	24.7	16.7	11.8	8.6	6.8	5.4
	$VSIEWMA_3(d_1 = 0.5)$	176.2	154.7	107.8	68.7	42.5	27.3	18.6	13.4	10.1	8.1	6.6
0.10	$EWMA_3$	132.1	122.1	94.6	66.4	44.9	30.7	21.9	16.6	13.1	10.6	8.9
	$VSIEWMA_3(d_1 = 0.1)$	126.0	114.3	85.2	56.1	35.6	22.5	14.9	10.4	7.6	6.0	4.8
	$VSIEWMA_3(d_1 = 0.25)$	129.3	115.2	85.7	57.1	36.9	23.3	15.8	11.3	8.5	6.6	5.4
	$VSIEWMA_3(d_1 = 0.5)$	128.9	116.7	88.1	60.4	38.6	25.9	18.2	13.2	10.1	7.9	6.6
0.15	$EWMA_3$	88.6	84.6	70.8	54.5	39.6	28.5	20.9	16.1	12.8	10.4	8.8
	$VSIEWMA_3(d_1 = 0.1)$	80.1	75.1	61.2	43.9	29.6	20.0	13.6	9.6	7.3	5.7	4.6
	$VSIEWMA_3(d_1 = 0.25)$	82.7	77.7	62.6	44.6	31.1	21.2	14.9	10.9	8.3	6.6	5.4
	$VSIEWMA_3(d_1 = 0.5)$	84.7	79.7	64.9	47.7	34.2	23.3	16.6	12.5	9.8	7.8	6.5
0.20	$EWMA_3$	59.7	57.1	51.1	42.4	33.3	25.4	19.5	15.4	12.4	10.2	8.7
	$VSIEWMA_3(d_1 = 0.1)$	50.5	48.1	41.1	31.9	24.1	17.2	12.1	9.1	6.9	5.5	4.4
	$VSIEWMA_3(d_1 = 0.25)$	51.2	50.3	42.3	33.7	25.6	18.2	13.6	10.1	7.8	6.2	5.1
	$VSIEWMA_3(d_1 = 0.5)$	53.6	52.2	44.9	36.7	27.8	20.4	15.6	11.9	9.3	7.6	6.3
λ 0.25	$EWMA_3$	39.8	39.5	36.5	32.3	27.1	22.0	17.8	14.4	11.9	10.0	8.5
	$VSIEWMA_3(d_1 = 0.1)$	31.1	30.8	27.0	23.4	18.1	13.9	10.7	8.1	6.5	5.2	4.3
	$VSIEWMA_3(d_1 = 0.25)$	33.0	32.4	28.9	24.8	19.6	15.2	11.7	9.2	7.3	6.0	5.0
	$VSIEWMA_3(d_1 = 0.5)$	35.4	33.9	31.6	27.3	21.9	17.5	13.7	11.0	8.9	7.3	6.2
0.30	$EWMA_3$	28.2	28.2	26.9	24.7	22.0	18.8	15.7	13.2	11.2	9.6	8.3
	$VSIEWMA_3(d_1 = 0.1)$	20.5	20.2	18.5	16.7	13.9	11.3	9.1	7.3	5.9	4.9	4.1
	$VSIEWMA_3(d_1 = 0.25)$	21.9	21.7	20.0	17.8	15.1	12.4	9.9	8.3	6.7	5.7	4.8
	$VSIEWMA_3(d_1 = 0.5)$	24.6	23.5	22.2	20.4	17.5	14.7	11.9	9.9	8.2	6.9	5.9
0.35	$EWMA_3$	21.0	20.9	20.2	19.1	17.6	15.8	13.9	12.1	10.5	9.1	8.0
	$VSIEWMA_3(d_1 = 0.1)$	14.1	13.8	13.2	12.0	10.6	9.1	7.6	6.4	5.3	4.5	3.9
	$VSIEWMA_3(d_1 = 0.25)$	15.3	15.2	14.4	13.3	11.7	10.2	8.6	7.3	6.2	5.2	4.5
	$VSIEWMA_3(d_1 = 0.5)$	16.9	17.0	16.3	15.1	13.7	12.1	10.3	8.9	7.6	6.5	5.6
0.40	$EWMA_3$	16.2	16.2	15.9	15.3	14.5	13.5	12.1	10.9	9.7	8.6	7.6
	$VSIEWMA_3(d_1 = 0.1)$	10.2	10.1	9.8	9.2	8.3	7.5	6.5	5.6	4.8	4.2	3.7
	$VSIEWMA_3(d_1 = 0.25)$	11.2	11.2	10.7	10.0	9.2	8.4	7.3	6.4	5.5	4.9	4.3
	$VSIEWMA_3(d_1 = 0.5)$	12.8	12.8	12.4	11.9	11.0	9.9	8.9	7.9	6.9	6.1	5.4
0.45	$EWMA_3$	13.1	13.1	12.9	12.6	12.1	11.4	10.6	9.8	8.9	8.0	7.3
	$VSIEWMA_3(d_1 = 0.1)$	7.8	7.7	7.5	7.2	6.7	6.1	5.5	4.9	4.3	3.8	3.4
	$VSIEWMA_3(d_1 = 0.25)$	8.6	8.5	8.3	8.0	7.4	7.0	6.3	5.6	5.0	4.5	4.0
	$VSIEWMA_3(d_1 = 0.5)$	10.1	10.1	9.8	9.6	9.1	8.5	7.7	7.1	6.3	5.7	5.1
0.50	$EWMA_3$	10.8	10.8	10.8	10.6	10.3	9.9	9.3	8.7	8.1	7.5	6.9
	$VSIEWMA_3(d_1 = 0.1)$	6.2	6.2	5.9	5.8	5.4	5.1	4.7	4.3	3.9	3.5	3.2
	$VSIEWMA_3(d_1 = 0.25)$	7.0	6.9	6.7	6.5	6.2	5.8	5.5	5.0	4.6	4.1	3.7
	$VSIEWMA_3(d_1 = 0.5)$	8.2	8.1	7.9	7.8	7.5	7.2	6.7	6.3	5.7	5.2	4.8

the rows labeled "$EWMA_3$" are the AATS of the traditional linear profile monitoring method of Kim et al. (2003) and the rows labeled "$VSIEWMA_3$" are the AATS of our proposed VSI $EWMA_3$.

From Tables 1–2, we have the following observations.

(1) It is clear that adding the VSI feature to the linear profile monitor-

Table 2
AATS comparisons with $EWMA_3$ under deviation shifts from σ to $\gamma\sigma$

γ	1.2	1.4	1.6	1.8	2.0	2.2	2.4	2.6	2.8	3.0
$EWMA_3$	33.5	12.7	7.2	5.1	3.9	3.2	2.8	2.5	2.3	2.1
$VSIEWMA_3(d_1 = 0.1)$	27.4	8.3	4.0	2.5	1.6	1.2	0.9	0.7	0.6	0.5
$VSIEWMA_3(d_1 = 0.25)$	28.6	9.1	4.6	2.8	2.0	1.5	1.2	1.0	0.8	0.7
$VSIEWMA_3(d_1 = 0.5)$	30.2	10.3	5.4	3.6	2.6	2.1	1.7	1.5	1.3	1.2

ing method of Kim et al. (2003) substantially improves the efficiency of the chart. The out-of-control AATS can have a 57%–98%, 54%–98% and 24%–82% off for intercept shifts, slope shifts and standard deviation shifts, respectively. For the combinations of intercept and slope shifts, the out-of-control AATS can have a 46%–98% off.

(2) The time reduction becomes larger as the shifts get larger. This implies that adding VSI feature to the linear profile monitoring method has more benefit for larger process shifts. This is different from other control charts, such as $\overline{X}$, CUSUM and EWMA control charts, where adding VSI feature is more effective for small to moderate process shifts. The reason may be that when a process has a larger process shift, the shorter sampling interval d_1 is used most of the time.

(3) With some exceptions, such as $\lambda = 0, \delta = 0.025, 0.05$, control charts with smaller d_1 have smaller AATS, which is consistent with previous research on VSI control charts.

4.2   Comparison with VSI MEWMA and VSI ELR

To compare with the results of Zou et al. (2007) and Zhang et al. (2009), the underlying model is the same with the model used by Kim et al. (2003). The AATS comparisons under intercept shifts from B_0 to $B_0 + \lambda\sigma$ and under deviation shifts from σ to $\gamma\sigma$ are shown in Tables 3–4, respectively, with the lines labeled "VSI MEWMA" being the AATS of the VSI MEWMA of Zou et al. (2007) and the lines labeled "VSI ELR" being the AATS of the VSI ELR of Zhang et al. (2009). Note that the smoothing parameter $\theta = 0.2$ in Zou et al. (2007) and Zhang et al. (2009). We use the same smoothing parameter to make fair comparisons, although we can use different θ for different shifts to get optimal results.

From Tables 3–4, we have the following observations.

(1) For intercept shifts, for $\lambda > 0.1$, the VSI $EWMA_3$ slightly outperforms both the VSI MEWMA and the VSI ELR. In particular, with respect to the VSI MEWMA, the advantage of the VSI $EWMA_3$ is more evident

13

Table 3
AATS comparisons with VSI MEWMA and VSI ELR under shifts from B_0 to $B_0 + \lambda\sigma$

	λ	0.1	0.2	0.3	0.4	0.5	0.6	0.8	1.0	1.5	2.0	3.0
$d_1 = 0.5$	$VSIMEWMA$	124.4	51.9	23.3	12.6	8.0	5.7	3.6	2.6	1.6	1.1	0.7
	$VSIELR$	122.8	52.1	23.9	13.1	8.4	6.0	3.8	2.8	1.6	1.0	0.5
	$VSIEWMA_3$	124.3	50.8	22.8	12.4	7.9	5.8	3.8	2.9	1.9	1.5	1.1
$d_1 = 0.25$	$VSIMEWMA$	122.2	48.3	20.4	10.6	6.6	4.8	3.1	2.3	1.4	1.0	0.8
	$VSIELR$	117.1	47.6	20.7	10.9	6.7	4.8	3.0	2.2	1.4	0.9	0.5
	$VSIEWMA_3$	121.5	47.5	19.1	10.0	6.1	4.5	2.9	2.2	1.4	1.1	0.8
$d_1 = 0.1$	$VSIMEWMA$	120.0	45.2	18.1	9.2	5.8	4.2	2.8	2.1	1.4	1.1	0.9
	$VSIELR$	112.2	44.2	18.0	9.2	5.7	4.2	2.8	2.2	1.4	0.9	0.5
	$VSIEWMA_3$	119.1	42.1	16.4	7.7	4.8	3.4	2.2	1.7	1.0	0.8	0.6

Table 4
AATS comparisons with VSI MEWMA and VSI ELR under shifts from σ to $\gamma\sigma$

	γ	1.1	1.2	1.4	1.8	2.2	2.6	3.0
$d_1 = 0.5$	$VSIMEWMA$	68.9	27.4	14.1	8.8	3.2	1.9	1.1
	$VSIELR$	68.3	24.1	7.1	2.6	1.6	1.1	0.9
	$VSIEWMA_3$	66.5	27.0	9.5	3.5	2.3	1.8	1.5
$d_1 = 0.25$	$VSIMEWMA$	66.3	25.2	12.5	7.7	2.7	1.7	1.1
	$VSIELR$	65.7	22.1	6.1	2.2	1.4	1.1	0.9
	$VSIEWMA_3$	61.7	25.0	8.0	2.7	1.6	1.3	1.1
$d_1 = 0.1$	$VSIMEWMA$	63.9	23.4	11.4	6.9	2.6	1.7	1.2
	$VSIELR$	63.6	20.7	5.6	2.2	1.4	1.1	0.9
	$VSIEWMA_3$	57.5	21.8	6.1	1.9	1.2	0.9	0.8

for a smaller value of d_1. We will not report our result under shifts in slope because it is, however, similar to the case under shifts in intercept based on our simulation results.

(2) For deviation shifts, our proposed VSI $EWMA_3$ is designed for detecting up-sided shifts. When the shift size is larger than 1, our method has uniformly better performance than VSI MEWMA with only one exception when $\gamma = 3.0$, $d_1 = 0.5$. However, for $\gamma > 1.1$, the VSI $EWMA_3$ is never better than the VSI ELR throughout the three values of d_1.

Although our proposed VSI $EWMA_3$ chart does not globally perform better than the VSI MEWMA and VSI ELR, it has its own advantages. First, the identification of the out-of-control profile parameters of VSI MEWMA is based on other three parametric tests, which makes the application so complex that practitioners may be reluctant to take extra effort to diagnose which parameter has changed after they get an out-of-control signal. While our VSI $EWMA_3$ inherits the advantage of $EWMA_3$ that the three EWMA statistics are independent, so it does not need extra diagnostic aids. We can have some idea of the cause of a shift by seeing which one of the three monitoring statistics is the maximum. Second, there are four EWMA statistics involved in VSI ELR and three in our VSI $EWMA_3$, which makes the computation of our VSI $EWMA_3$ a little easier. Third, VSI MEWMA and VSI ELR can not control individual in-control average false alarm rate as our VSI $EWMA_3$ because their control charts employ one control limit L while our VSI $EWMA_3$ can use L_I, L_S and L_E to control average false alarm rate for intercept, slope and standard deviation, respectively, if a manager does not think the statistics E_I, E_S and E_E are equally important. We think these features of our VSI $EWMA_3$ could be appealing for managers and practitioners.

5 A real data example

In this section, the VSI $EWMA_3$ is illustrated by a real data example Gupta et al. (2006) use to compare the performance of two methods. The data set consists of line widths of photo masks reference standards on 10 units (40 measurements) used for monitoring linear calibration profiles of an optical imaging system. The line widths are used to estimate the parameters of the linear calibration profile, $y_{ij} = 0.2817 + 0.9767x_i$, with a residual standard deviation of 0.06826 micrometers. The data set is presented in Table 7 of Gupta et al. (2006).

In order to be consistent with Equation (1), the original data has been standardized by

Table 5
Results of the example

No	E_I	E_S	E_E	SE_I	SE_S	SE_E	Δ	d
1	4.510	0.979	0.123	0.398	0.164	0.130	0.398	0.100
2	4.502	0.977	0.079	0.194	0.004	0.084	0.194	1.225
3	4.504	0.978	0.000	0.234	0.101	0.000	0.234	1.225
4	4.524	0.990	0.543	0.736	1.178	0.575	1.178*	1.225
5	4.522	0.991	0.238	0.684	1.232	0.252	1.232	0.100
6	4.522	0.989	0.000	0.692	1.088	0.000	1.088	0.100

$$\frac{y_{ij}}{0.06826} = \left(\frac{0.2817}{0.06826} + \frac{0.9767}{0.06826}\bar{x} \right) + \frac{0.9767}{0.06826}x_i^* + \epsilon_{ij}^{'},$$

where $\epsilon_{ij}^{'} \sim N(0,1)$. The parameters $p_0 = 0.8$ and $d_1 = 0.1$ are used for the VSI $EWMA_3$. The results are listed in Table 5. The columns labeled "E_I", "E_S", "E_E", "SE_I", "SE_S", "SE_E" and "Δ" are defined in Equation (2), (5) and (6), correspondingly. The last column is the sampling interval employed. Note that there is an out-of-control signal for the 4th sample because $\Delta(4) = 1.178 > 1$. This is consistent with the result of Gupta et al. (2006). The time used to detect this shift is $0.100 + 1.225 \times 3 = 3.775$ for the VSI $EWMA_3$.

Gupta et al. (2006) replace the EWMA charts of $EWMA_3$ by $\overline{X}$ charts to monitor the intercept and slope and by an S^2 chart to monitor the error variance, which we call $EWMA_3 - Shewhart$. Although all the $EWMA_3 - Shewhart$ of Gupta et al. (2006), the ELR of Zhang et al. (2009) and the VSI $EWMA_3$ give an out-of-control signal for the 4th sample, there are some differences in identifying causes for the shift. For the VSI $EWMA_3$, we can easily find this shift is mainly caused by the shift of the slope because $SE_S(4) = 1.178$ is the maximum. Note that the ELR chart of Zhang et al. (2009) concludes that this shift signal is caused by a deviation shift. Gupta et al. (2006), on the other hand, find that there are problems for both slope and deviation. But they also notice that the deviation values for the 5th and 6th sample are below the lower control limit, which implies the signal for deviation is not so strong. So the conclusion made by our VSI $EWMA_3$ that the shift is mainly caused by slope seems reasonable. Considering this sample data set is small, further research may be needed to identify the causes of the shift for this real data application.

6 Computational aspects

The Fortran programs used in previous sections are available from the authors upon request. A user can also code his own computer program by the guidelines below for finding ω.

(1) Input parameters to be specified by the practitioners, including $x_1, x_2, \ldots,$ $x_n, p_0, d_1, L_I, L_S, L_E$.

(2) Set the maximum of ω to $\omega_{max} = 1$ and the minimum of ω to $\omega_{min} = 0$ and set $\omega = (\omega_{max} + \omega_{min})/2$.

(3) Set $ATS = 0$. Generate standard normal random variables to compute y_{ij} and obtain $\Delta(j)$. If $\Delta(j) > \omega$, update ATS to $ATS = ATS + d_1$ and update ATS to $ATS = ATS + d_2$ otherwise.

(4) Repeat step (3) B times which is the Monte Carlo sample size and obtain the average of the ATS. If ATS>in-control ARL, update ω_{max} to ω; otherwise, update ω_{min} to ω.

(5) The algorithm is not stopped until the absolute difference of ATS and in-control ARL is less than a prefixed value ε.

Based on the algorithm above, all the results are implemented in Fortran 95 with IMSL package. Routine "rnnor" is used to generate standard normal random variables. The computation time is highly correlated to the total Monte Carlo sample size B and the prefixed value ε. Hence larger value of B and smaller values of ε will lead the result with higher accuracy, but more time consuming, and vice versa. To balance the time and accuracy, we recommend that $B = 5000$ and $\varepsilon = 1$. The execution time is less than 10 seconds on a Pentium 4 with CPU processor 3.00 GHz.

7 Conclusion and extension

In this paper, we propose an EWMA scheme with variable sampling intervals for monitoring linear profiles. The proposed chart has the following positive features: 1) it can be designed and constructed with just two additional parameters, the conditional probability p_0 and the shorter sampling interval d_1; 2) it is quite robust and sensitive to various types of shifts, including intercept shifts, slope shifts, standard deviation shifts and combinations of intercept and slope shifts; 3) it does not need extra diagnostic aids; 4) it can control the individual in-control average false alarm rate.

The properties of VSI $EWMA_3$ have been in this paper under the assumption that the observations from the process are normally distributed. For some processes, this assumption may not be realistic. The VSI feature could of

course be used with non-normal observations, but in this case, the properties and design strategies would need to be developed under a model which allows for non-normality. Lin and Chou (2005b) study the design of VSS and VSI $\overline{X}$ charts under non-normality based on Burr distribution. This warrants further research.

Acknowledgement

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Figure captions:

Figure 1. log(AATS) for $p_0 = 0.5(0.1)0.9, d_1 = 0.1$.

Figure 2. log(AATS) for $d_1 = 0.1(0.1)0.5, p_0 = 0.8$.